

07-11-00

102 x 2  
1746  
8

ATMI-272  
PATENT APPLICATION

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**



**23448**

PATENT TRADEMARK OFFICE

In re United States Patent Application of:

Applicant: **Van Buskirk et al.**

Serial No.: **09/093,291**

Date Filed: **June 8, 1998**

Title: **ISOTROPIC DRY CLEANING  
PROCESS FOR NOBLE METAL  
INTEGRATED CIRCUIT  
STRUCTURES**



Examiner: **A. Olsen**

Group Art Unit: **1746**

**EXPRESS MAIL CERTIFICATE**

I hereby certify that I am mailing the attached documents to the Commissioner for Patents on the date specified below, in an Express Mail envelope addressed to the Commissioner for Patents, Washington, DC 20231, and Express Mailed under the provisions of 37 CFR 1.10.

*Lee Ann Brown*

Lee Ann Brown

July 10, 2000

Date of Mailing

EL569017110US

Express Mail Certificate

**AMENDMENT RESPONDING TO APRIL 12, 2000 OFFICE ACTION IN  
U.S. PATENT APPLICATION NO. 09/093,291**

Commissioner for Patents  
Washington, D.C. 20231

Sir:

In response to the April 12, 2000 Office Action in the above-identified United States Patent Application (the "Office Action"), please amend the application as follows:

**In the specification:**

At page 2, insert the following as an independent paragraph immediately preceding "BACKGROUND OF THE INVENTION":

07/10/2000 VPDLITE1 00000001 09093291

01 PG. 002

156.00 GP

RECEIVED  
JUL 19 2000  
TO 1100 MAIL ROOM  
6/19  
200  
7-20-00

B